

IN THE ABSTRACT:

Please amend the Abstract as follows:

A gating device to delimit an x-ray beam, ~~said gating device comprising~~ has a device housing, first and second absorber elements mounted in ~~said the~~ device housing opposite each other, and ~~an adjustment device connected to said first and second absorber elements for moving said the~~ absorber elements relative to each other to set a spacing ~~between said first and second absorber elements therebetween~~ forming a slit for passage of an x-ray beam therethrough, ~~each of said absorber elements having an~~ . Each absorber element has an edge shaped to give ~~said the~~ slit a slit width that varies in a longitudinal direction of the slit, ~~said slit width increasing that increases~~ outwardly~~[[,]]~~ from a central position~~[[,]]~~ toward respectively opposite ends of ~~said the~~ slit, ~~each~~ . Each slit edge has , ~~in said longitudinal direction of said slit, having a middle region producing a uniform width of said the~~ slit and~~[[,]]~~ further regions respectively disposed on opposite sides of ~~said the~~ middle region that produce a linearly, longitudinally increasing slit width ~~in said longitudinal direction of said slit, . The~~ and ~~said adjustment device producing~~ produces a parallelogram-like relative movement between ~~said the~~ absorber elements.